



FUAI Photoelectric Technology (Shenzhen) Co., Ltd.

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Confidentiality Request Letter

Reason for Amendment (current / obsolete)	Revision History		Approved Date
	From	To	
Initial Release (obsolete)	1.0	1.0	Nov-14-2006
Adding CFR 2.459 (obsolete)	1.0	2.0	August – 11 - 2008
Updated company template & Added text box (obsolete)	2.0	3.0	Jan-31-2012
Added IC confidentiality letter form (obsolete)	3.0	4.0	March-26-2015
Corrections to STC form. Added reference to KDB (current)	4.0	5.0	Nov 19 2015

FUAI Photoelectric Technology (Shenzhen) Co., Ltd.

2016-07-23

To:
Federal Communications Commission
Authorization and Evaluation Division
7435 Oakland Mills Road
Columbia, MD

Subject: **Permanent Confidentiality Request** for FCC ID: [2A18E-FATL031](#)


Pursuant to sections 0.457 and 0.459 of CFR 47, we respectfully request permanent confidential treatment of the following Exhibits accompanying this application as:

- [Block Diagram](#)
- [Schematics](#)
- [Operational Description](#)

The above materials contain trade secrets and proprietary information not customarily released to the public. The public disclosure of these materials may be harmful to the applicant and provide unjustified benefits to its competitors.

The applicant understands that disclosure of this application and all accompanying documentation will not be made before the date of the Grant for this application.

Sincerely,

Client's signature : 

Client's name & title : [Jian Yang/ Manager](#)

Contact information / address: [Jingkai Building 303 Room, The Silicon Valley Power Qinghu Park C2 Building, Longhua New District, Shenzhen, China](#)